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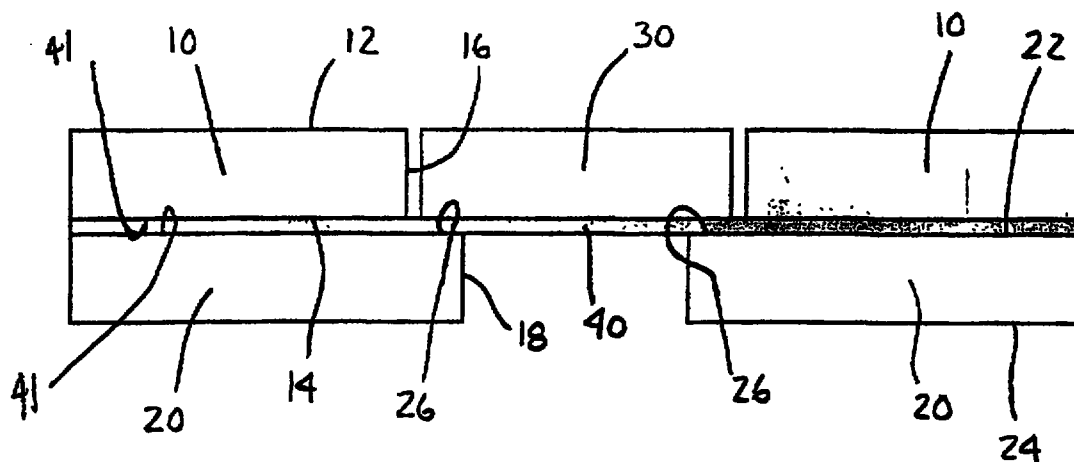
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(54) Title: POLISHING PAD



(57) Abstract: A polishing pad for use with a polishing fluid has, a polishing layer (10), a window (30) in an opening (16) through the polishing layer, and a fluid impermeable layer (40) spanning across the polishing layer and the window and the opening to provide an uninterrupted continuous barrier to leakage of polishing fluid, the fluid impermeable layer having thereon an adhesive forming bond seals with the polishing layer and the window.